

Cell K Y Wong

List of Publications by Year in descending order

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11
papers

175
citations

1684188

5
h-index

2053705

5
g-index

11
all docs

11
docs citations

11
times ranked

221
citing authors

| # | ARTICLE | IF | CITATIONS |
|----|--|-----|-----------|
| 1 | Molecular modeling of temperature dependence of solubility parameters for amorphous polymers. Journal of Molecular Modeling, 2012, 18, 2333-2341. | 1.8 | 67 |
| 2 | Functionalization-induced changes in the structural and physical properties of amorphous polyaniline: a first-principles and molecular dynamics study. Scientific Reports, 2016, 6, 20621. | 3.3 | 40 |
| 3 | Interfacial Adhesion Study for SAM Induced Covalent Bonded Copper-EMC Interface by Molecular Dynamics Simulation. IEEE Transactions on Components and Packaging Technologies, 2008, 31, 297-308. | 1.3 | 24 |
| 4 | Thiol-based self-assembly nanostructures in promoting interfacial adhesion for copper-epoxy joint. Applied Physics Letters, 2009, 94, . | 3.3 | 19 |
| 5 | Thiol based chemical treatment as adhesion promoter for Cu-epoxy interface. , 2008, , . | | 6 |
| 6 | A multiscale method to predict delamination in Cu-epoxy systems in electronic packages. , 2009, , . | | 6 |
| 7 | Synergistic Toughening of Epoxyâ€“Copper Interface Using a Thiol-Based Coupling Layer. Journal of Adhesion Science and Technology, 2011, 25, 2081-2099. | 2.6 | 5 |
| 8 | Hydrophobic self assembly molecular layer for reliable Cu-epoxy interface. , 2009, , . | | 4 |
| 9 | Hydrophobic self-assembly monolayer structure for reduction of interfacial moisture diffusion. , 2009, , . | | 4 |
| 10 | Kinetics Study of Disulfide Self Assembly Monolayer (SAM) Deposition for Cu-EMC Adhesion Promotion. , 2006, , . | | 0 |
| 11 | Kinetic Study of Disulfide Molecular Film Deposition for Cu-EMC Adhesion Promotion. Electronics Manufacturing Technology Symposium (IEMT), IEEE/CPMT International, 2006, , . | 0.0 | 0 |